

Supporting Information

Protective Dissolution: Generating Secondary Pores in Zeolite by Mechanochemical Reaction

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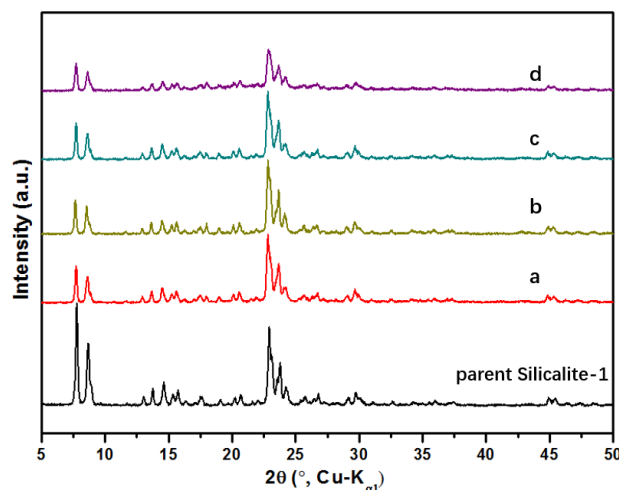


Fig. S1 PXRd patterns of Silicalite-1 treated with different contents of NH₄F alone in the solvent-free mechanochemical treatment: (a) NH₄/SiO₂=0.54, (b) NH₄/SiO₂=1.08, (c) NH₄/SiO₂=1.62, (d) NH₄/SiO₂=2.70.

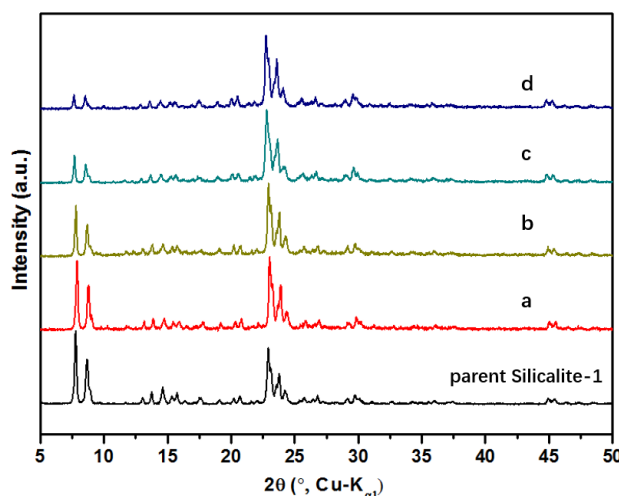


Fig. S2 PXRd patterns of Silicalite-1 treated with different content TPABr alone in solvent-free mechanochemical treatment: (a) TPABr/SiO₂=0.075, (b) TPABr/SiO₂=0.15, (c) TPABr/SiO₂=0.225, (d) TPABr/SiO₂=0.375.

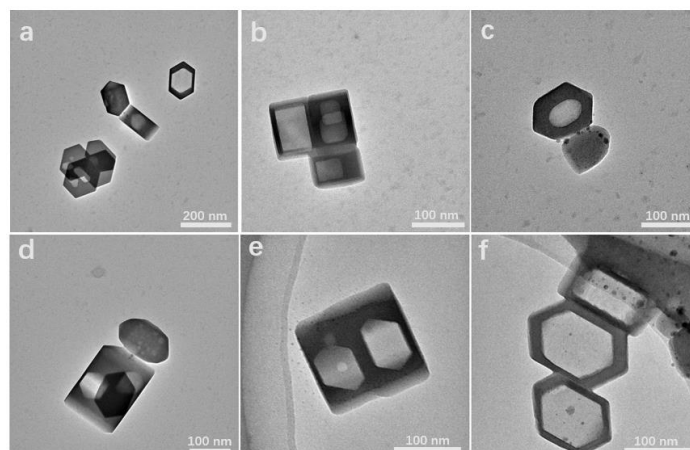


Fig. S3 TEM images of Silicalite-1 treated with different content of NH_4F -TPABr in the solvent-free mechanochemical treatment: (a) $\text{NH}_4/\text{SiO}_2=0.3$, $\text{TPABr}/\text{SiO}_2=0.075$; (b) $\text{NH}_4/\text{SiO}_2=0.6$, $\text{TPABr}/\text{SiO}_2=0.075$; (c) $\text{NH}_4/\text{SiO}_2=1.0$, $\text{TPABr}/\text{SiO}_2=0.075$; (d) $\text{NH}_4/\text{SiO}_2=0.54$, $\text{TPABr}/\text{SiO}_2=0.10$; (e) $\text{NH}_4/\text{SiO}_2=0.54$, $\text{TPABr}/\text{SiO}_2=0.15$; (f) $\text{NH}_4/\text{SiO}_2=0.54$, $\text{TPABr}/\text{SiO}_2=0.225$.

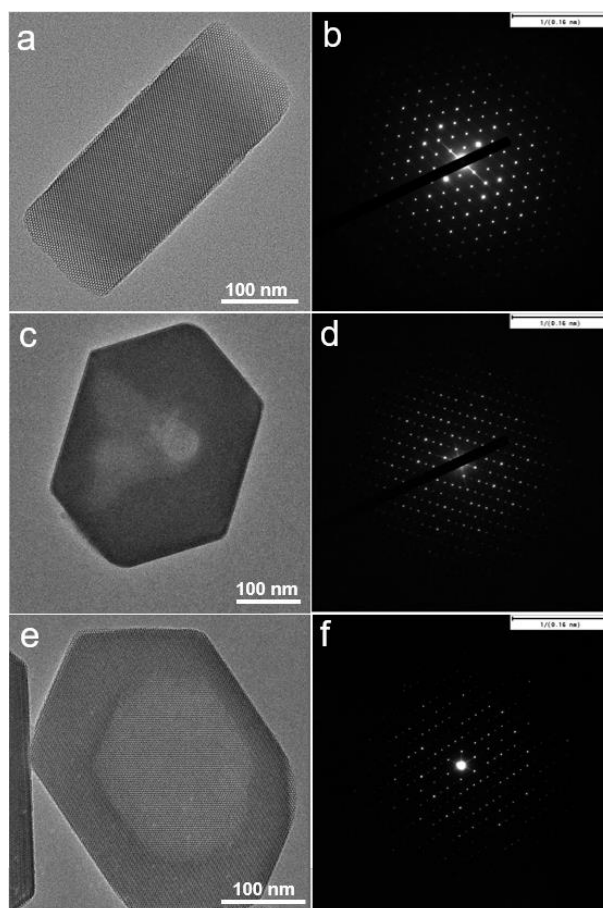


Fig. S4 TEM images and SAED patterns of (a, b) pristine silicalite-1 zeolite, (c, d) ground products and (e, f) ground-heated sample.

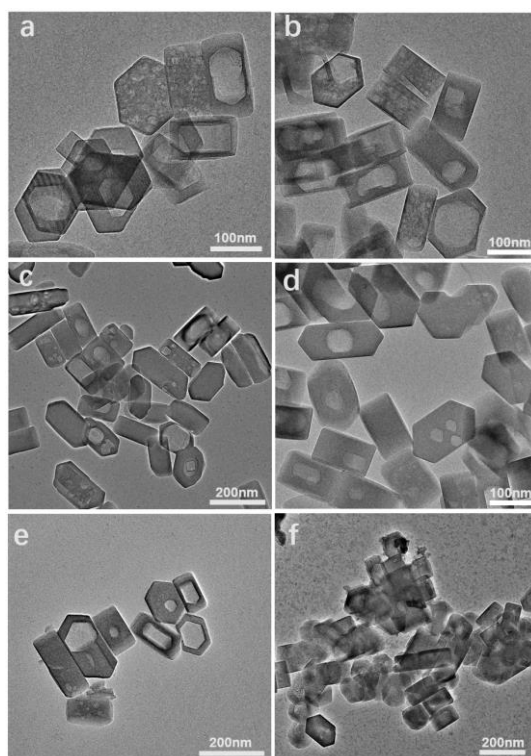


Fig. S5 TEM images of Silicalite-1 treated by solvent-free method at 80 °C, 100 °C, 120 °C, 150 °C, 180 °C, 220 °C for 15 h.

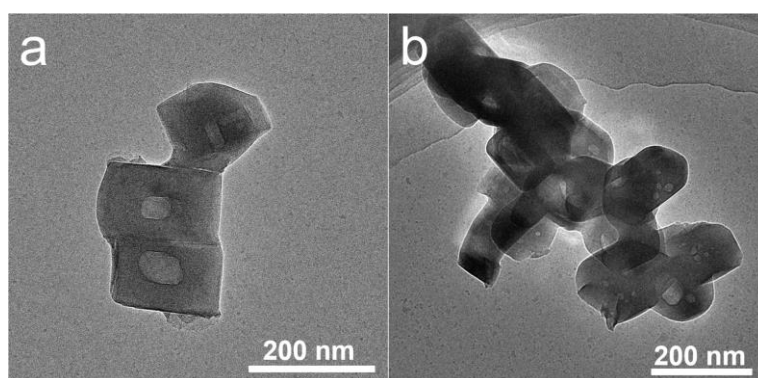


Fig. S6 TEM images of Silicalite-1 treated by solvent-free method at 180 °C for 7 d.

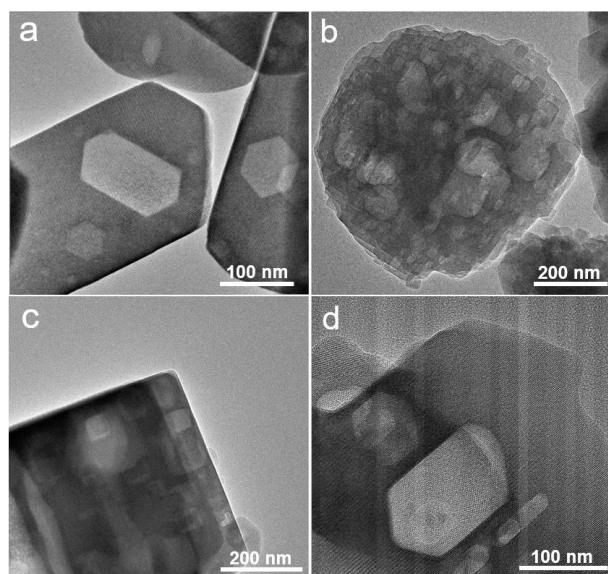


Fig. S7 TEM images of commercial Silicalite-1(a), ZSM-5 with Si/Al =50 (b), ZSM-5 with Si/Al=14 (c), ZSM-5 with Si/Al=13 (d) treated by solvent-free method.

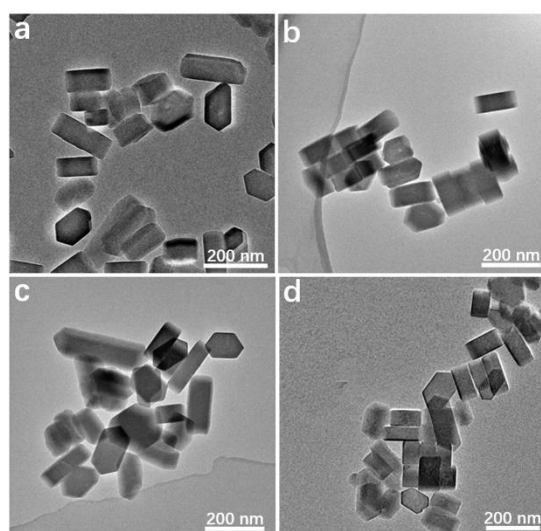


Fig. S8 TEM images of Silicalite-1 treated with different contents of TPABr alone in the solvent-free mechanochemical treatment: (a) TPABr/SiO₂=0.075, (b) TPABr/SiO₂=0.15, (c) TPABr/SiO₂=0.225, (d) TPABr/SiO₂=0.375.

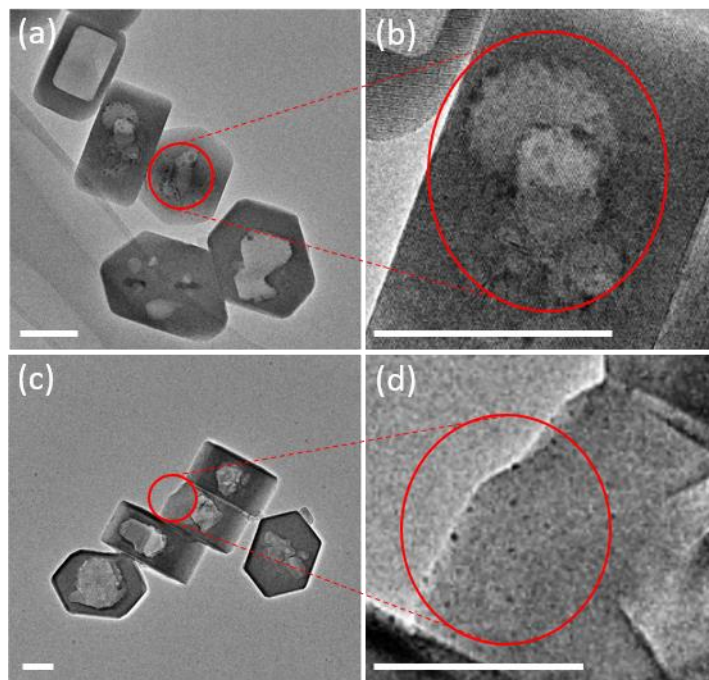


Fig. S9 TEM images of (a, b) Co@Silicalite-1 and (c, d) Pd@Silicalite-1 after mixing and heating process but without calcination and reduction.

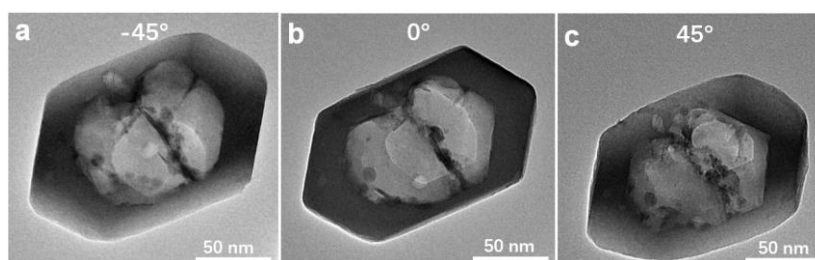


Fig. S10 TEM images of Co@Silicalite-1 at different tilting angles.